to the same of the	Application No.	Applicant(s)
	7.55.00	
Notice of Allowability	10/710,237 Examiner	TSENG, SHIEN CHUN
nodes of Amorability	Examiner	Art Unit
	Khanh B. Duong	2822
The MAILING DATE of this communication apperature of the communication apperature of the series allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	(OR REMAINS) CLOSED i or other appropriate comm IGHTS. This application is	n this application. If not included unication will be mailed in due course. THIS
1. \boxtimes This communication is responsive to <u>the filing of the applic</u>	cation on June 28, 2004.	
2. ☑ The allowed claim(s) is/are <u>1-11</u> .		
 3. Acknowledgment is made of a claim for foreign priority unal All b) Some* c) None of the: 1. Certified copies of the priority documents have 2. Certified copies of the priority documents have 	e been received.	
	• •	
 Copies of the certified copies of the priority do International Bureau (PCT Rule 17.2(a)). 	cuments have been receive	ed in this national stage application from the
* Certified copies not received:		
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONN THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		e a reply complying with the requirements
4. A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which give		
5. CORRECTED DRAWINGS (as "replacement sheets") mus	st be submitted.	
(a) I including changes required by the Notice of Draftspers	son's Patent Drawing Revie	w (PTO-948) attached
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date		
(b) ☐ including changes required by the attached Examiner's Paper No./Mail Date		
Identifying indicia such as the application number (see 37 CFR 1 each sheet. Replacement sheet(s) should be labeled as such in t		
 DEPOSIT OF and/or INFORMATION about the depo attached Examiner's comment regarding REQUIREMENT 	SIT OF BIOLOGICAL MAT FOR THE DEPOSIT OF BIO	ERIAL must be submitted. Note the OLOGICAL MATERIAL.
Attachment(s)		
1. Notice of References Cited (PTO-892)		formal Patent Application (PTO-152)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. ☐ Interview S Paper No.	ummary (PTO-413), /Mail Date
3. Information Disclosure Statements (PTO-1449 or PTO/SB/C Paper No./Mail Date	08), 7. ☐ Examiner's	Amendment/Comment
Examiner's Comment Regarding Requirement for Deposit of Biological Material	8. 🛭 Examiner's	Statement of Reasons for Allowance
	9. 🗌 Other	-

Art Unit: 2822

DETAILED ACTION

This office action is in response to the filing of the application on June 28, 2004.

Accordingly, claims 1-11 are pending.

Allowable Subject Matter

Claims 1-11 are allowed.

The following is an examiner's statement of reasons for allowance: none of the prior art of record, taken alone or in combination, fairly shows or suggests all the limitations as claimed.

Re claim 1, none of the prior art of record fairly discloses a method for fabricating a through hole comprising: forming a patterned first photoresist layer on the substrate and the conductive structure to define at least a pattern of a through hole; performing a first etching process to remove the cap layer not covered by the first photoresist layer until at least a first portion of the conductive layer is exposed; removing the first photoresist layer; forming a dielectric layer and a patterned second photoresist layer on the substrate in sequence, wherein a pattern of the second photoresist layer is the same as a pattern of the first photoresist layer; and performing a second etching process to remove the dielectric layer not covered by the second photoresist layer until the first portion of the conductive layer is exposed.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Art Unit: 2822

Conclusion

The prior art made of record and not relied upon is considered pertinent to applicant's disclosure.

The following U.S. Patents teaches methods of forming through holes relative to conductive structures: Dass '101, Fahn '396, Shin 568, Abraham '007, Shields '504 and Watanabe '663. However, none of the cited patents, taken alone or in combination, fairly discloses or suggests all the limitations as claimed.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Khanh B. Duong whose telephone number is (571) 272-1836. The examiner can normally be reached on 10:00-6:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Amir Zarabian can be reached on (571) 272-1852. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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